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Semiconductor Detectors

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Silicon Detector



Germanium Detector

Outline of this Lecture

Introduction

- Detectors General Requirements
- Why use semiconductor detectors?

Basic Principles

- P-type, N-type
- Depletion layer
- Type of detectors

Performance

- Energy Measurement
- Position Measurement
- Timing Measurement

> Electronics



Detectors General Requirements [Particle Identification]

Hadrons

proton, neutron, d, t, 3He, ... pion, kaon, ...

Photon

Gamma-ray (y)

Lepton

Electron (β), Muon (μ), Tau(τ) Neutrino (ν)



We want to detect the particle positively. - what kind of particles?! - momentum, direction, time, etc..

Detectors Requirements

Energy measurement

- Energy loss (dE)
- Total energy (E)
- Pulse shape

Position measurement

- (X, Y, Z) \rightarrow Tracking
- $B\rho \rightarrow Momentum (p)$

> Timing measurement

- Timing (velocity β)
- High counting rate (dN/dt)

Count measurement

- Sensitivity to particle (ε)
- Insensitive to background (S/N)
- Radiation hardness

There are many types of detectors.

- Scintillation detector (Suda-san)
- Gas detector
- Semiconductor detector

 \rightarrow Is there a perfect detector ?!

What is the advantage of semiconductor detector?

Why Semiconductor?

Low ionization energy			
 good signal 		Ionization	Energy
Long mean free path	Detector	energy	resolution
 good charge collection efficiency 		I (eV)	@ 5MeV 2.35/√ (5x10 ⁶ /I)
High mobility			· · · · · · · · · · · · · · · · · · ·
 fast charge collection 	Scintillation	100 ~ 500	1.1 ~ 2.4 %
Si Lower Z = 14			
 low multiple scattering 	Gas	30	0.6 %
Little cooling			
Ge Higher Z = 32	Semiconductor	2	0.20/
 higher stopping power 		3	0.270
 Cooling is required. 			

Energy required for creation of an electron-hole pair



Sand

Silicon: The basic ingredients are ridiculously cheap

C.A.Klein, J. Applied Physics 38 (1968) 2029.

Basic Principles



Basic Principles [To dope the silicon with impurities]

Boron doping (p-type) holes are majority carriers



Phosphorus doping (n-type) electrons are majority carriers



Basic Principles

Now we can construct a p-n junction



P. Collins (CERN)

Basic Principles



When brought together to form a junction, the majority diffuse carriers across the junction. The migration leaves a region of net charge of opposite sign on each side, called the space-charge region or depletion region. The electric field set up in the region prevents further migration of carriers.

concentration Space charge density Carrier density Electric field Electric potential

P. Collins (CERN)

Now for the magic part !

Basic Principles [Semiconductor structure]



- Use ionization signal left behind by charged particle passage.
- Ionization produces electron(e)-ion(h) pairs, use electric field to drift the e and h to the oppositely charged electrodes.
- Si needs 3.6eV to produce one e-h pair.

Depletion zone

Depletion zone

 $w = \sqrt{2\epsilon\rho\mu V_b}$

where $\rho = 1/q\mu N$ for doped materiel and N is the doping concentration (q is always the charge of the electron)



The voltage needed to completely deplete a device of thickness d is called the depletion voltage, V_d

 $V_d = d^2 / (2\epsilon\rho\mu)$



Types of Silicon detectors

Strip devices

- High precision
- Large active area
- Single-sided or Double-sided
- > Pixel devices
 - True 2-D measurement
 - Small areas, but high track density
- > Pad devices
 - (Big pixels / wide strips)
 - Pre-shower and calorimeters
- Drift devices



Types of Ge-detectors





Closed-ended coaxial

represents electrical contact surface



Closed-ended coaxial (bulletized)



Figure 12.3 At the top are shown the three common shapes of large-volume coaxial detectors. Each represents a cross-sectional view through the axis of a cylindrical crystal. The outer electrode is extended over the flat front (left) surface in both closed-ended cases. Cross sections perpendicular to the cylindrical axis of the crystal are shown at the bottom. The HPGe material may be either high-purity p or ntype. The corresponding electrode configurations are shown for each type.



Strip Ge detector

Clover Detector

Liquid Nitrogen for cooling





4 crystals



Performance I

Energy Resolution

Energy Resolution





If Signal Variance << Baseline Variance → Electronics (baseline) noise critical for resolution



Figure 4.5 Definition of detector resolution. For peaks whose shape is Gaussian with standard deviation σ , the FWHM is given by 2.35 σ .

Energy Resolution : Nal(TI) vs Ge



Figure 12.7 Comparative pulse height spectra recorded using a sodium iodide scintillator and a Ge(Li) detector. The source was gamma radiation from the decay of ^{108m}Ag and ^{110m}Ag. Energies of peaks are labeled in keV. (From Philippot.¹³)

Semiconductor detector Excellent detector for energy measurement !!

Energy Resolution [Signal to Background Ratio (S/N)]



G.A. Armantrout, et al., IEEE Trans. Nucl. Sci. NS-19/1 (1972) 107

→ Good Energy Resolution → Higher Statistics

We can extract - precise peak position, - and find NEW Peaks!!

Particle Identification [Use Difference of Stopping Power]

$$p = m_0 \beta \gamma$$
$$\frac{dE}{dx} \propto \frac{1}{\beta^2} \ln(\beta^2 \gamma^2)$$

Knowing p and β gives m

For very low momenta, we can exploit the bethe-bloch formula for particle identification



Particle Identification [dE-E Correlation]



Multi-layer detectors enable us to identify the particles!



 \cap

 \cap

Energy Resolution :

[Temperature Dependence]







Semiconductor Detectors prefer COOLING !

Performance II

Position Measurement



Bubble chamber (CERN)

Position Measurement

Table 28.1: Typical resolutions and deadtimes of common detectors. Revised September 2003 by R. Kadel (LBNL).

Detector Type	Accuracy (rms)	Resolution Time	Dead Time
Bubble chamber	10–150 μm	$1 \mathrm{ms}$	50 ms^a
Streamer chamber	$300 \ \mu m$	$2 \ \mu s$	$100 \mathrm{ms}$
Proportional chamber	$50-300 \ \mu m^{b,c,d}$	2 ns	200 ns
Drift chamber	$50-300 \ \mu m$	2 ns^e	100 ns
Scintillator		100 ps/n^f	10 ns
Emulsion	$1 \mu \mathrm{m}$		
Liquid Argon Drift [7]	$\sim 175 - 450 \ \mu m$	$\sim 200 \text{ ns}$	$\sim 2 \ \mu s$
Gas Micro Strip [8]	$30-40 \ \mu m$	< 10 ns	
Resistive Plate chamber [9]	$\lesssim 10 \ \mu { m m}$	12 ns	
Silicon strip	$pitch/(3 to 7)^g$	h	h
Silicon pixel	$2 \ \mu m^i$	h	h

a	Multiple pulsing time.
b	$300 \ \mu \text{m}$ is for 1 mm pitch.
c	Delay line cathode readout can give $\pm 150 \ \mu m$ parallel to
	anode wire.
d	wirespacing/ $\sqrt{12}$.
e	For two chambers.
f	n = index of refraction.
g	The highest resolution ("7") is obtained for small-pitch
	detectors ($\leq 25 \ \mu m$) with pulse-height-weighted center
	finding.
h	Limited by the readout electronics [10]. (Time resolution o
	< 25 ns is planned for the ATLAS SCT)

 i Analog readout of 34 $\mu{\rm m}$ pitch, monolithic pixel detectors.

Silicon Detectors

- very good position resolution.
- works under high magnetic field.
- high rates and triggering.

Position Measurement







 $\sigma = \text{pitch}/\sqrt{12}$

Position Sensitive Ge detectors







Ge detector array (GRAPE) CNS, Univ. of Tokyo



Performance III

Timing Measurement

Silicon detector

- Electrons ~10ns/300um
- Holes ~ 25ns/300um



Timing Measurement

2. Nuclear Mass Spectroscopy by Time-of-Flight

Two silicon detectors

First detector thin, so that particle passes through it (transmission detector)

 \Rightarrow differential energy loss ΔE

Second detector thick enough to stop particle

 \Rightarrow Residual energy E

Measure time-of-flight Δt between the two detectors





(H. Spieler et al., Z. Phys. A278 (1976) 241)

Electronics



Noise is a big issue for Silicon/Ge detectors. At 22000 e- for a 300 um thick silicon sensor, the signal is relatively small. Signal losses can easily occur depending on electronics, stray capacitances, coupling capacitor, frequency etc.

> Improve energy resolution> Allow a low detection threshold

Electronics [Signal Integration on Input Capacitance]

System response depends on detector capacitance !

Energy Deposit ∝ Charge Qd However,

☆ Detector capacitance C_{DET} may vary within a system or change with bias voltage.
 ☆ Variation of charge collection in time T_c

Make system whose gain (dV_{out}/dQ_s) is independent of detector capacitance.

Charge sensitive preamp !

Charge Collection

 ➢ Isolation of each strip using high impedance bias connection
 → Collect / measure charge on each strip

AC couple input amplifier
 (usually)
 Avoid large DC input currents

Signals

- (a) Output of preamp
- (b) Output of shaping amp
- (c) Undershoot
- (d) Base-line shift

The output of preamplifier : rapidly rising step, followed by a slow exponential decay. Amplitude of the step = energy of the detected radiation Exponential decay time = feedback resistor in parallel with the feedback capacitor.

Shaping Time

Figure 28.20: Equivalent noise charge vs shaping time. Changing the voltage or current noise contribution shifts the noise minimum. Increased voltage noise is shown as an example.

Optimization is required in shaping time, $\sim 1 \ \mu s$

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Electronics : Pile-up

Shielding and Loops

a) Shielding

Clearly, the area A enclosed by any loops should be minimized.

Accomplished by routing signal line and return as a closely spaced pair.

Better yet is a twisted pair, where the voltages induced in successive twists cancel.

Problems occur when alternating detector electrodes are read out at opposite ends – often done because of mechanical constraints.

How to use them

Operation

DELICATE Devices

> HV should be increased SLOWLY..

- Check its maximum HV value and Polarity (+/-)
- Check the current in HV module and its signal carefully.
- If something is wrong, stop the operation and investigate the reason.
- Shock / vibration may destroy the detector.
 - Careful handling.

Silicon detectors

- Only the support frame can be touched.
- Silicon detector hates moisture.
- Sensitive to photons (light) ... Operate in dark place.

Ge-detector

Liquid nitrogen is required to cool the detector down.

Summary

- Semiconductor detectors based on the simple principle of the p-n junction.
- > Si is typically used for charged particle & X-ray
- > Ge is used for γ ray spectroscopy.

Friday afternoon, Practical training using Ge detector (by Watanabe-san)

I wish you all the best for enjoying your stay in JAPAN !!

References

> SLAC Lecture

- <u>http://www-group.slac.stanford.edu/sluo/lectures/Detector-</u> <u>Lectures.html</u>
- Silicon Detector by Paula Collins
 - http://lhcb-doc.web.cern.ch/lhcbdoc/presentations/lectures/CollinsItacuruca03-2nd.pdf
- REVIEW OF PARTICLE PHYSICS, Phys. Letters B 667 (2008).
- EG&G ORTEC, Modular Pulse-Processing Electronics and Semiconductor Radiation Detectors.
- GLENN F. KNOLL, Radiation Detection and Measurement.

Particle Identification (PID) Isomeric states as Flag of PID

Energy Calibration

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30. COMMONLY USED RADIOACTIVE SOURCES

Table 30.1. Revised November 1993 by E. Browne (LBNL).

			Particle		Photon		
		Type of	Energy	Emission	Energy Emission		
Nuclide	Half-life	decay	(MeV)	prob.	(MeV) prob.		
²² Na	2.603 y	β^+ , EC	0.545	90%	0.511 Annih.		
					1.275 100%		
54 Mn	0.855 y	EC			0.835 100%		
					Cr K x rays 26%		
55Fe	2.73 y	EC			Mn K x rays:		
20	-				0.00590 24.4%		
					0.00649 2.86%		
57Co	0.744 v	EC			0.014 9%		
21					0.122 86%		
					0.136 11%		
					Fe K x rays 58%		
⁶⁰ Co	5.271 v	B	0.316	100%	1.173 100%		
21					1.333 100%		
68 32Ge	0.742 y	EC			Ga K x rays 44%		
6 R							
$\rightarrow \frac{99}{31}Ga$	L	β^+ , EC	1.899	90%	0.511 Annih.		
					1.077 3%		
90 Sr 38 Sr	28.5 y	β^{-}	0.546	100%			
$\rightarrow \frac{90}{39}Y$		β^{-}	2.283	100%			
$^{106}_{44}Ru$	1.020 y	β^{-}	0.039	100%			
105m					0.540 0407		
$\rightarrow \frac{1}{45}R$	h	ρ^{-}	3.541	79%	0.512 21%		
100					0.622 10%		
48Cd	1.267 y	\mathbf{EC}	0.063 e	41%	0.088 3.6%		
			0.084 e	45%	Ag K x rays 100%		
119			0.067 e	976			
50Sn	0.315 y	EC	0.364 e	- 29%	0.392 65%		
			0.388 c	- 6%	In K x rays 97%		
¹³⁷ 55Cs	30.2 y	β^{-}	0.514	94%	0.662 85%		
			1.176	6%			
133Ba	10.54 v	EC	0.045 e	50%	0.081 34%		
56	10.01		0.075 e	- 6%	0.356 62%		
					Cs K x rays 121%		
207 Bi	31.8 v	EC	0.481 c	- 2%	0.569 98%		
83			0.975 c	- 7%	1.063 75%		
			1.047 c	2%	1.770 7%		
					Pb K x rays 78%		
²²⁸ Th	1.912 v	6a:	5.341 to	8.785	0.239 44%		
50		3β-:	0.334 to	2.246	0.583 31%		
					2.614 36%		
$(\rightarrow \frac{224}{88}Ra$	$\rightarrow \frac{220}{86}$ F	ln → ²	216Po	$\rightarrow \frac{212}{82}Pb$ ·	$\rightarrow {}^{212}_{83}Bi \rightarrow {}^{212}_{84}Po)$		
²⁴¹ Am	432.7 y	α	5.443	13%	0.060 36%		
			5.486	85%	Np L x rays 38%		
²⁴¹ Am/Be	432.2 v	6×10	⁻⁵ neut	rons (4-8 M	eV) and		
30.007,000		4×10	-5γ 's (4	1.43 MeV) p	er Am decay		
244 Cm	18 11		5 769	9494	Pu L x rans co 0%		
96'0'	10.11 y	CE	5.805	76%	• a L x tays ~ 976		
²⁵² Cf	2.645 v	a (97%)	6.076	15%			
98.00	2.000 9	(21.70)	6.118	82%			
		Fission	(3.1%)				
		≈ 2	$0 \gamma' s/fis$	sion; 80% <	1 MeV		
≈ 4 neutrons/fission; $(E_n) = 2.14$ MeV							

"Emission probability" is the probability per decay of a given emission; because of cascades these may total more than 100%. Only principal emissions are listed. EC means electron capture, and e^- means monoenergetic internal conversion (Auger) electron. The intensity of 0.511 MeV e^+e^- annihilation photons depends upon the number of stopped positrons. Endpoint β^{\pm} energies are listed. In some cases when energies are closely spaced, the γ -ray values are approximate weighted averages. Radiation from short-lived daughter isotopes is included where relevant.

Half-lives, energies, and intensities are from E. Browne and R.B. Firestone, Table of Radioactive Isotopes (John Wiley & Sons, New York, 1986), recent Nuclear Data Sheets, and X-ray and Gamma-ray Standards for Detector Calibration, IAEA-TECDOC-619 (1991).

Neutron data are from Neutron Sources for Basic Physics and Applications (Pergamon Press, 1983).

